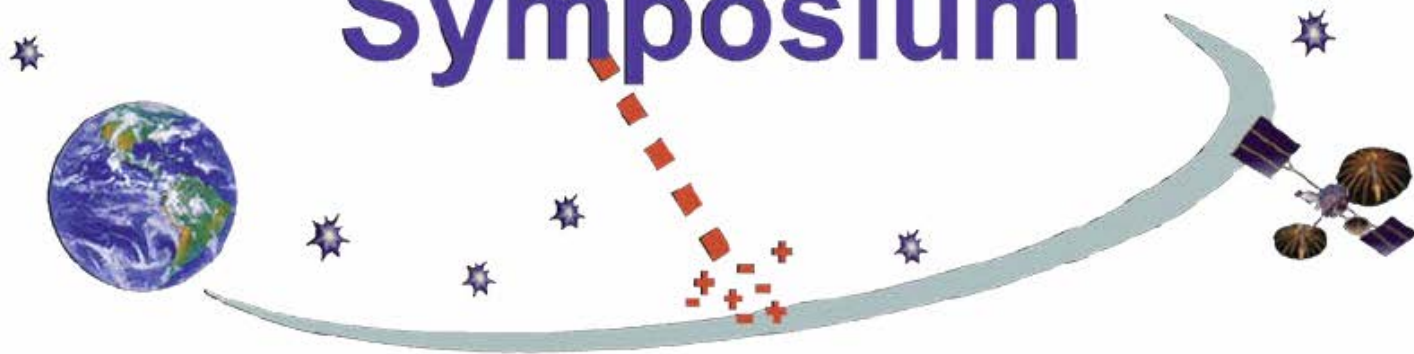


2012 Single Event Effects Symposium



San Diego, April 3rd – 5th, 2012

Conference agenda

List of sessions:

- Design and Process Hardening
- Single Event Test Facilities
- SEE on Commercial Memories
- Single-Event Transients
- Single-Event Test Methods
- Destructive SEE
- Product, Technology, System SEE

Conference agenda

- Lot of space and army oriented topics
- Memory test (NAND flash), Point of load DC/DC converters, ADC converters, FPGAs...
- SET
- Mitigation techniques like “scrubing” (removing errors from a memory's content by re-writing it periodically with correct values)
- SEL protection by an adjustable over current detection that forces a power cycling of the full system in case of SEL detection
- Device hardening by placement of redundant blocks sufficiently far apart to not be influenced by the same incident particle

Quantity of laser aided diagnostics

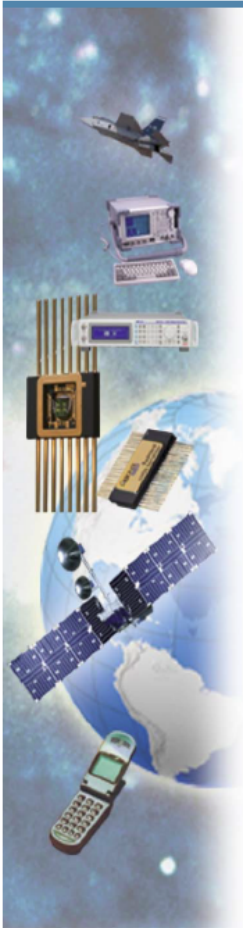
AEROFLEX

Single Event Functional Interrupt Location and Elimination via Pulsed Laser Scanning on a RadHard CMOS 16-bit ADC

Alfio Zanchi, Shinichi Hisano, Craig Hafer, and David B. Kerwin

Aeroflex Colorado Springs, Inc. – Colorado Springs, CO

SEE Symposium – San Diego, CA (U.S.A.) – April 3rd, 2012



SET effects due to E-H in various blocks

Pulsed laser scanning

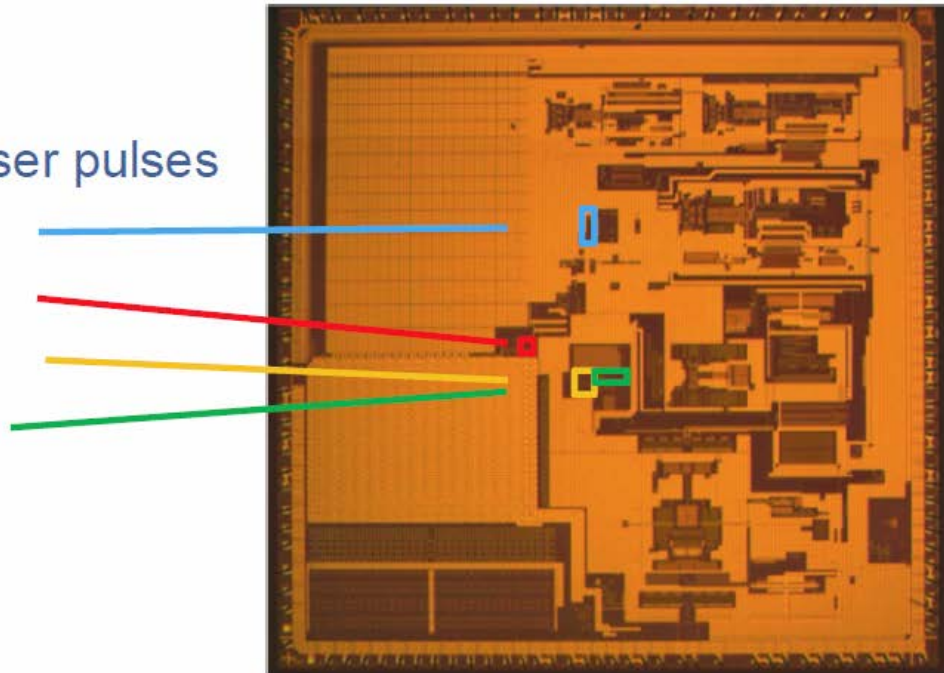
AEROFLEX

▼ Factors of uncertainty of the test

- no direct pulse energy sense (photodiode) available in Aeroflex
- is metallization completely open over sensitive block: no de-rating?

▼ Areas subject to laser pulses

- Bandgap
- POR
- VREF generator
- Voltage drivers



Studies of SET with short X-ray pulses



Single Event Transients Induced by the Absorption of Picosecond X-ray Pulses

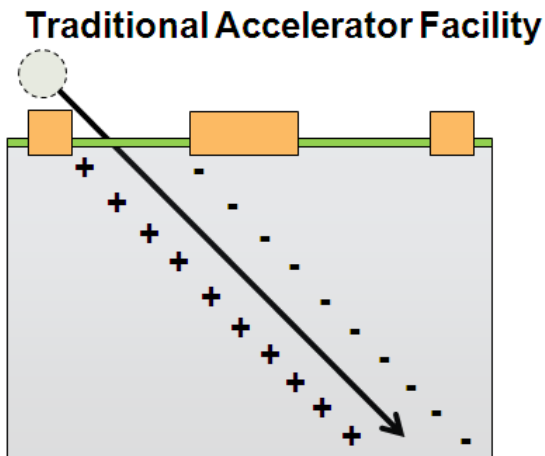
David Cardoza, Stephen D. LaLumondiere, Michael A. Tockstein,
Steven C. Witczak, Yongkun Sin, William T. Lotshaw and Steven C. Moss

The Electronics and Photonics Laboratory
The Aerospace Corporation

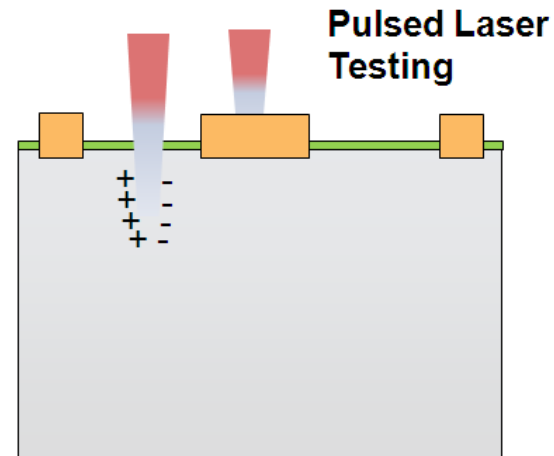
4 April 2012

SEU location by Laser or X-ray

Motivation for Short X-ray Pulses



- **Large Penetration Depth**
 - Generates Charge Tracks
- **Penetrates Metallization**
- **Unless microbeam facility or mask used, difficult to spatially locate upset location.**



- **Focusable – relatively high spatial resolution.**
- **Charge carriers generated in skin-depth volume around focus**
- **Unable to penetrate metallization**
- **Two photon techniques can be used to evade metallization via backside illumination.**

XILINX FPGA Devices SEE evaluation



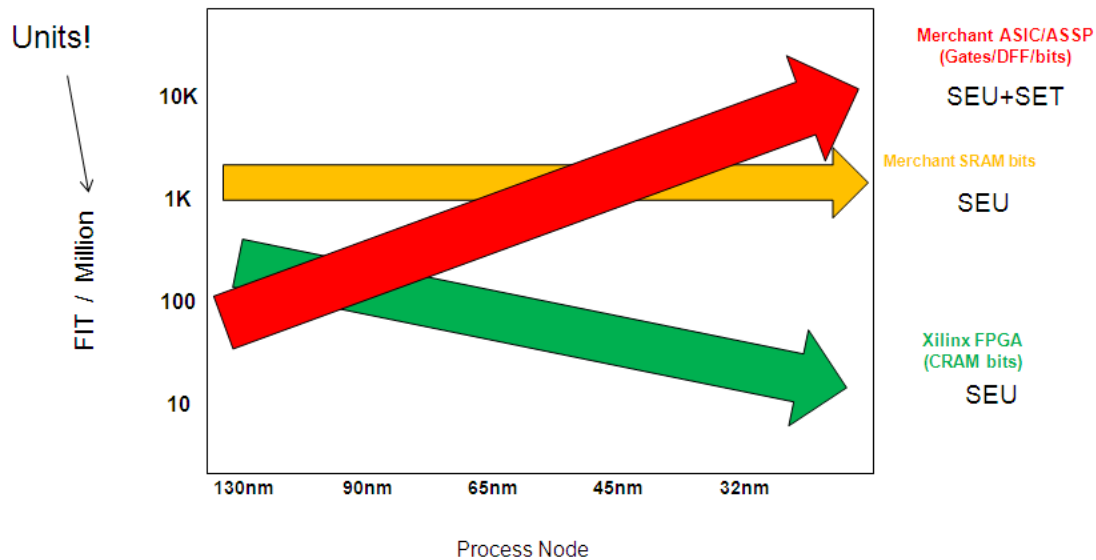
**From 250nm to 28nm
Terrestrial SER
Xilinx FPGA Devices**

Austin Lesea

XILINX FPGA Devices SEE evaluation

Advances in protection of the configuration memory

Xilinx View: our per bit FIT gets better



Destructive test of IGBTs



Trench Fieldstop Insulated Gate Bipolar Transistor (IGBT) failures at ground level

Antoine Touboul, Lionel Foro, Frédéric Wrobel, Frédéric Saigné

Destructive test of IGBTs



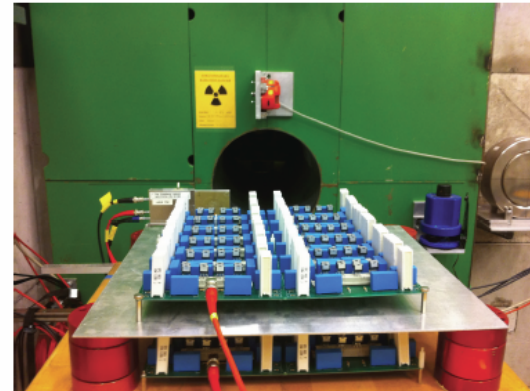
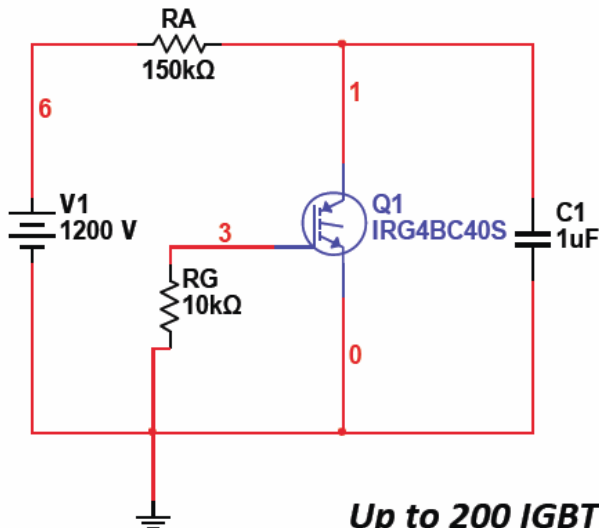
1200V-IGBT failures under ANITA atmospheric like spectrum, TSL

Sensitive state for SEE triggering is OFF state

$$V_{CE} \text{ from } 70\% \text{ to } 100\% \text{ of } V_{CEMAX}$$
$$V_{GE} = 0V$$

Contrary to test of digital devices, the failure does not affect a bit but the whole device itself.

1 failure=1 device lost
Hard to get good statistics



Up to 200 IGBT tested in the same time

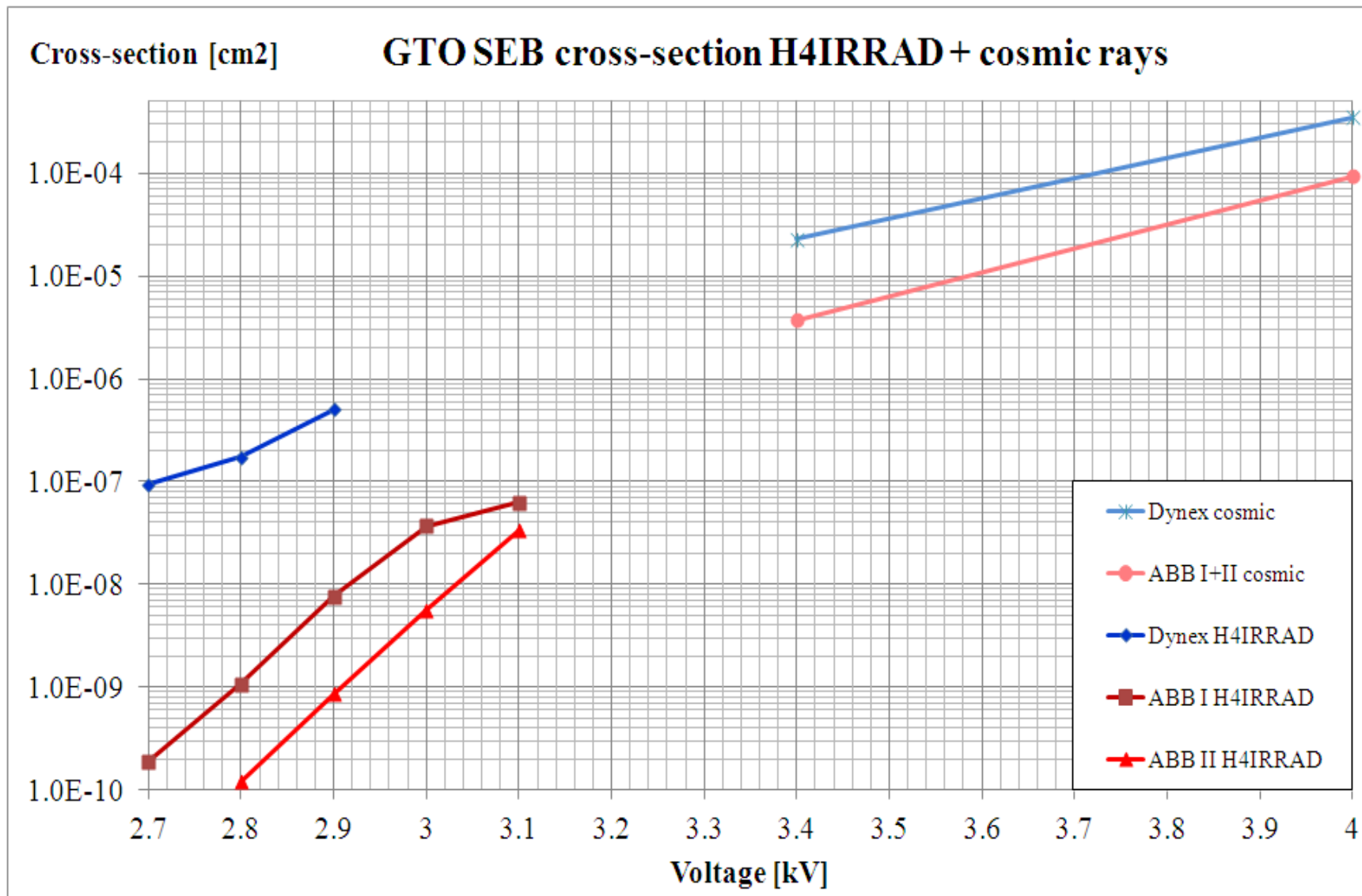
Conference agenda

Non-destructive SEB tests of HV GTO-like thyristors



Viliam Senaj, Laurent Ducimetière
CERN, Switzerland

Conference agenda



Conference agenda

Measurement output example

- Influence of experienced SEBs to c-s measurement - Dynex at 2.7 kV:
 - c-s = $1,22 \cdot 10^{-7} \text{ cm}^2$ after first 49 SEBs
 - c-s = $1,24 \cdot 10^{-7} \text{ cm}^2$ after 99 SEBs
 - c-s = $0,92 \cdot 10^{-7} \text{ cm}^2$ after 162 SEBs

